



Verification of InGaAs photodiode proton irradiation results.

 Development of irradiation degradation prediction models for InGaAs photodiodes.





- Verification by means of <u>Non lonising</u> <u>Energy Loss</u>
- NIEL in different materials using TRIM
 - NIEL in different materials using GEANT4



NIEL for GaAs

*Method suggested by Messenger et all in "Nonionizing Energy Loss for Heavy Ions"



★ SRIM method is compatible with tabulated values in literature.

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NIEL for Silicon

. H # = # | | | | | # = # # #

• NIEL as a function of the incident particle energy derived by SRIM data:



- Good agreement at low energies
- Tabulated data gives higher values of NIEL for energies above 10MeV.

(SRIM limitation to Coulomb and non-relativistic interactions).

esa Bi₁₂ SiO₂₀ - hologram in ISS

★Bismuth Silicon Oxide: Bi= 12; Si= 1; O = 20.

*The base for the hologram : recorded on the complete thickness, with a section of about 3 x 3 mm².





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esa NIEL for Bi₁₂ SiO₂₀



Threshold energy for atomic displacement used for Bi, Si and O atoms was 10eV, binding energy was 2eV.

Threshold energy used for Bi was
25eV, for Si was 21eV and for O was 28eV.
Binding energy used was 3eV.

* Threshold values within this energy range do **not** significantly influence the NIEL calculations for $Bi_{12}SiO_{20}$.



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Geometry is defined

- Elastic & Inelastic process are constructed for Protons, Neutrons, Deuteron, Triton & Alpha particles.
- Secondary Neutrons, Deuterons & Tritons with sufficient energy create displacement damage.



- an exercise to enable a better understanding of NIEL in different materials.
- GEANT4 is being used to compute NIEL because it enables the implementation of inelastic interaction.
- Next Step is to use the experience gained in GEANT4 to verify the results obtained for InGaAs photodiodes.